## **Question Paper**

**Marks: 100** 

Exam Date & Time: 22-Nov-2018 (10:00 AM - 01:00 PM)



## MANIPAL ACADEMY OF HIGHER EDUCATION

## **SCHOOL OF INFORMATION SCIENCES**

## FIRST SEMESTER MASTER OF ENGINEERING - ME (VLSI DESIGN) Digital Systems and VLSI Design [EDA 613]

**END SEMESTER DEGREE EXAMINATION NOVEMBER 2018** Answer all the questions. 1) With relevant sketches explain the different stages of (10)manufacturing solid state devices. 2) Explain the possible crystal defects and their effects after (10)the crystal is grown. 3) (10)Explain Silicon On Insulator (SOI) process with neat diagrams. (10)4) Explain, with a neat diagram, horizontal tube furnace system and its various sections used in thermal oxidation method. 5) a) With a neat diagram, describe the structure of a (10)MOSFET. (05) b) List the advantages of MOSFET over BIT. (05) 6) (10)What are the important second order effects in MOSFETs? Explain them briefly. 7) Explain the operation of a CMOS inverter, showing different (10) regions of operation. 8) State and prove the theorem specifying the condition for (10)zero short-circuit power consumption in a CMOS gate. 9) Derive a complete low frequency, small signal model for a (10)MOSFET with bulk effect. 10) Design a CMOS single bit full adder. Using this adder, (10)explain how do you construct a magnitude comparator circuit?

**Duration: 180 mins.** 

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